

“The Princess and the Pea” at the Nanoscale: Wrinkling and Delamination of Graphene on Nanoparticles

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Thin membranes exhibit complex responses to external forces or geometrical constraints. A familiar example is the wrinkling, exhibited by human skin, plant leaves, and fabrics, that results from the relative ease of bending versus stretching. Here, we study the wrinkling of graphene, the thinnest and stiffest known membrane, deposited on a silica substrate decorated with silica nanoparticles. At small nanoparticle density, monolayer graphene adheres to the substrate, detached only in small regions around the nanoparticles. With increasing nanoparticle density, we observe the formation of wrinkles which connect nanoparticles. Above a critical nanoparticle density, the wrinkles form a percolating network through the sample. As the graphene membrane is made thicker, global delamination from the substrate is observed. The observations can be well understood within a continuum-elastic model and have important implications for strain-engineering the electronic properties of graphene.

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I. INTRODUCTION

Thin films supported on substrates are of technological importance and are commonplace in biological systems such as cell walls and hard skins on soft plant and animal tissues. As the thickness t of a slab of material is reduced, it becomes more susceptible to out-of-plane deformation (bending) compared to in-plane deformation (stretching), resulting in morphological transitions. For example, thin films deposited on soft compliant substrates display wrinkling patterns under compressive stress [1], and membranes resting on fluids wrinkle by capillary forces [2]. This wrinkling is a ubiquitous phenomenon found in systems ranging from human skin to draping fabric [3–5] and has also been exploited to fabricate flexible electronic devices [6,7].

Because of the inextensible but bendable nature of the sp^2 carbon bond, graphene’s effective mechanical thickness $t_{\text{eff}} = (12\kappa/E_{2D})^{1/2}$ is less than 1 Å [8], where $\kappa \approx 1$ eV [9] is the bending rigidity and $E_{2D} \approx 2.12 \times 10^3$ eV/nm² [10] is the tensile rigidity; this is likely the smallest mechanical thickness ever achieved for any material. Graphene has been anticipated to exhibit a rich variety of wrinkling and delamination behaviors [11–16].

Although graphene adheres conformally to smooth nanoscale features with high fidelity [17], graphene wrinkling has been observed under compressive [18] or tensile [19] stress caused by thermal cycling, and graphene on periodically corrugated elastic [20] and metal [21] substrates exhibits transitions from adhesion to delamination. Morphological features such as wrinkles and conical singularities may produce a nonuniform strain in graphene [22], which produces both scalar and vector potentials and mimics the effect of a magnetic field on graphene’s electronic structure [23]. Recent experimental results suggest these effective “pseudomagnetic” fields can exceed several hundred tesla [24], and graphene devices based on “strain-engineering” have been proposed [25,26]. Understanding the mechanical response of graphene to nonuniform stress is thus a critical first step toward strain-engineering its electronic properties.

Here we report a systematic study of the wrinkling of graphene membranes supported on SiO₂ substrates with randomly placed topographic perturbations produced by SiO₂ nanoparticles. The wrinkling is probed as a function of nanoparticle density ρ_{np} and membrane thickness (using multilayer graphene). At low ρ_{np} , monolayer graphene largely conforms to the substrate except for small regions around the nanoparticles, where graphene is detached. Wrinkles (or folds or ridges) form as ρ_{np} increases, connecting pairs of protrusions. The observed maximum wrinkle length is predicted quantitatively within a simple elastic model. Above a critical density, the wrinkles

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percolate to form a network spanning the entire sample. As the thickness of graphene increases, it stiffens and delaminates instead of wrinkling. Since the wrinkling acts to remove inhomogeneous in-plane elastic strains through out-of-plane buckling, our results can be used to place limits on the possible in-plane strain magnitudes that may be created in graphene to realize strain-engineered electronic structures [22–26].

II. EXPERIMENTAL DETAILS

Silica-nanoparticle colloidal dispersions (Nissan Chemical America Corp., Snowtex-O) are diluted to various concentrations of 0.5–3.0 wt% by deionized water (Fisher Scientific, Water HPLC Grade). The diluted suspensions are sonicated for 30 min in a water bath to break agglomerations before spin coating the nanoparticles onto a substrate. Spin coating is performed on Si substrates with a 300-nm-thick oxide layer at 4000 rpm for 30 sec. The density of nanoparticles on substrates ranges from 2 to $258 \mu\text{m}^{-2}$, depending on the concentrations of the nanoparticle dispersions. After spin coating, the samples are completely dried on a hotplate at 150°C for 2 h. Graphene flakes are mechanically exfoliated from Kish graphite onto SiO_2 substrates covered with the silica nanoparticles (mean diameter 7.4 ± 2.2 nm, Ref. [27]). Thicknesses of graphene films are identified with an optical microscope, atomic force microscopy (AFM), and/or Raman spectroscopy. The sizes of graphene sheets are typically more than $10 \mu\text{m} \times 10 \mu\text{m}$, which is much larger than an estimated distance between nanoparticles of approximately 700 nm at the smallest nanoparticle density of $2 \mu\text{m}^{-2}$. Thus, we rule out the possibility of finite size effects in the following analyses. The samples are introduced into a vacuum chamber with a base pressure of approximately 10^{-7} Torr and annealed at 500°C for more than 5 h in order to remove any adhesive tape residue and to achieve equilibrium structures. After the annealing procedure, we observe surfaces of graphene flakes of various thicknesses in air using AFM in the tapping mode with silicon cantilevers with a nominal tip radius of less than 10 nm (Olympus, OMCL-AC160TS).

III. RESULTS AND DISCUSSION

A. Wrinkling of monolayer graphene

Figure 1 shows typical AFM images of monolayer graphene supported on nanoparticles for various densities ρ_{np} . At $\rho_{\text{np}} = 11 \mu\text{m}^{-2}$ [Fig. 1(a)], graphene adheres conformally to the substrate, as noted previously [17,28–30], with predominantly isolated protrusions at the nanoparticle locations. At $\rho_{\text{np}} = 22 \mu\text{m}^{-2}$ [Fig. 1(b)], some nanoparticle-induced protrusions are linked by wrinkles (we use the term “wrinkle” in accordance with the literature on graphene). Additional wrinkles with one free termination are also observed. The wrinkles between protrusions sag. If the protrusions have comparable heights as we assume below for simplicity, the wrinkle sags in the middle, while if the height difference is large, the wrinkle sags asymmetrically toward the protrusion of smaller height. With a further increase in nanoparticle density, the wrinkles connecting the protrusions proliferate [Fig. 1(c)], and ultimately a wrinkle network spans the sample [Figs. 1(d) and 1(e)]. These observations indicate the presence of a critical distance X_c between nanoparticles, below which wrinkling is induced.

We now analyze the critical nanoparticle separation X_c . The ridge running along the wrinkle between two nanoparticles with diameters d separated by X follows a catenarylike profile with a deflection $\zeta(x)$ as shown in Fig. 2(a). Additionally, as represented in Fig. 2(b), the profile of the ridge along the transverse (y) direction can be characterized with the dihedral angle θ and the curvature radius $C_0(x)^{-1}$. The contour of the wrinkle results from the balance between elasticity and adhesion. A wrinkle of length X , much larger than its average width W_{av} , costs adhesion energy $E_\Gamma \sim \Gamma X W_{\text{av}}$, where Γ is the graphene- SiO_2 adhesion energy per area. The deflection of elastic sheets between two protrusions creates a stretching strain $\epsilon \sim (\zeta_0/W_{\text{av}})^2$ along the crease of the ridge in a region of width approximately ζ_0 [31], where $\zeta_0 \equiv \zeta(0)$ is the maximum deflection. Balancing the stretching energy $E_s \sim E_{2D} X \zeta_0 \epsilon^2$ with the adhesion energy, and assuming that $W_{\text{av}} \sim d$, one finds that $\zeta_0 \sim X^{4/5} d^{1/5} (\Gamma/E_{2D})^{1/5}$. Precluding wrinkles with deflections larger than d , one finds a maximum wrinkle length $X_c \sim d(E_{2D}/\Gamma)^{1/4}$.

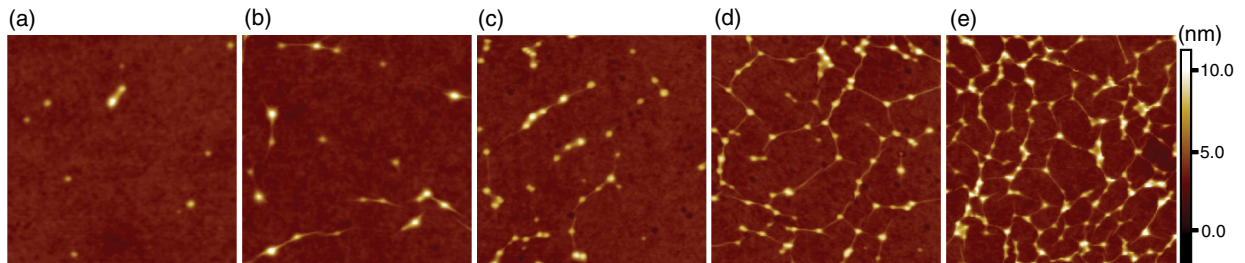


FIG. 1. AFM images ($1 \times 1 \mu\text{m}^2$) of graphene on SiO_2 nanoparticle/ SiO_2 substrates for a nanoparticle density of (a) 11, (b) 22, (c) 49, (d) 90, and (e) $170 \mu\text{m}^{-2}$, respectively.

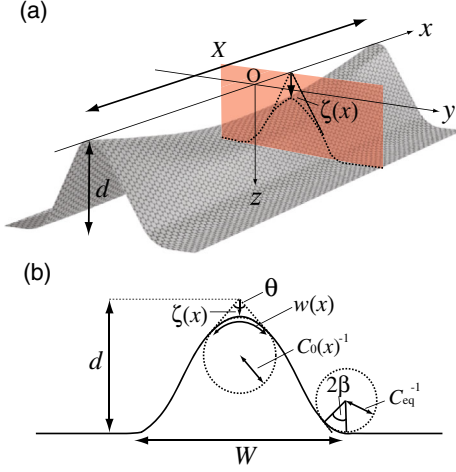


FIG. 2. Schematics of (a) a wrinkle formed between two nanoparticles with diameters d and (b) the wrinkle profile along the transverse direction as represented by shaded area in (a).

We next present a detailed elastic analysis of the wrinkle shape including bending energy, which provides an expression for the full deflection profile $\zeta(x)$ and recovers the scaling law for X_c . Assuming that the opening angle θ is independent of x as validated in Ref. [31], we find the width of the deformed region $w(x) = (\pi - \theta)C_0(x)^{-1}$ and the deflection $\zeta(x) = [1/\sin(\theta/2) - 1]C_0(x)^{-1}$ within the effective one-dimensional model. Furthermore, we assume that the stretching strain in the y direction is irrelevant according to Ref. [31]. Then, the stretching strain is also given in one dimension (in the x direction) by $\epsilon_x = [1 + (\partial_x \zeta)^2]^{1/2} - 1 \approx (\partial_x \zeta)^2/2$. We find the stretching energy E_s and the bending energy E_b :

$$E_s = \frac{E_{2D}}{2} \int dx w(x) \epsilon_x^2, \quad (1)$$

$$E_b = \frac{\kappa}{2} \int dx w(x) C_0(x)^2. \quad (2)$$

The adhesion energy cost is proportional to the area of the substrate uncovered by the membrane:

$$E_\Gamma = \Gamma \int dx W, \quad (3)$$

where W is the base of the wrinkle profile as illustrated in Fig. 2(b). In addition, we take into account bending and adhesion at the foot of the wrinkle, which cost bending energy $E_{b'}$ and adhesion energy $E_{\Gamma'}$ (see Appendix A for details), but these turn out to be negligible.

At equilibrium, we expect $\delta E_{\text{tot}}/\delta \zeta = 0$, where $E_{\text{tot}} = E_s + E_b + E_\Gamma + E_{b'} + E_{\Gamma'}$, leading to a differential equation for deflection ζ . By solving the differential equation under two boundary conditions $\zeta(\pm X/2) = 0$, we find the deflection on both sides of the center of the wrinkle (see Appendix A):

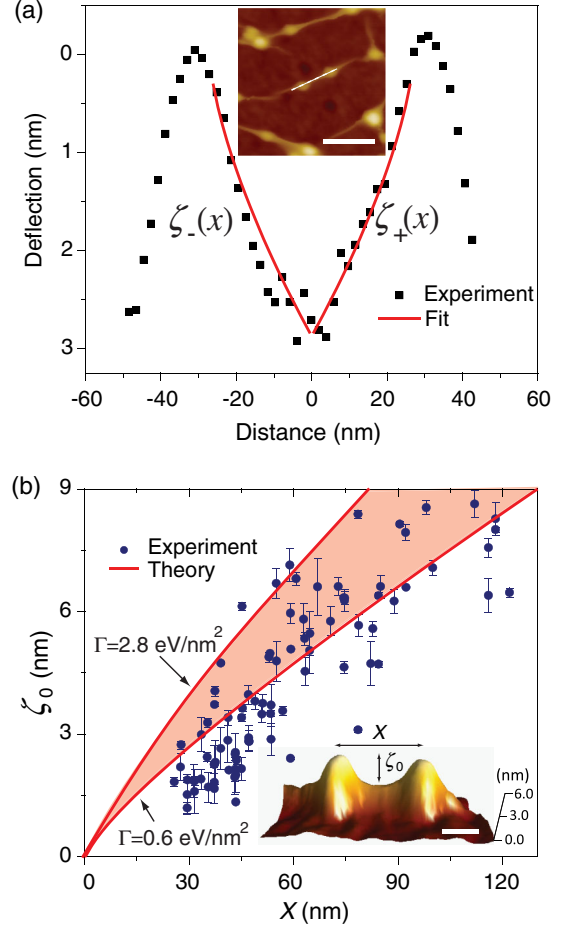


FIG. 3. (a) Profile of the wrinkle along the white dotted line in the AFM image shown in the inset. The scale bar in the inset is 50 nm. The solid red lines are theoretical expectations. (b) The maximum deflection ζ_0 as a function of the wrinkle length. The error bar indicates the uncertainty of ζ_0 due to the height difference between the protrusions. We choose wrinkles formed between protrusions where the height differences are less than 10%. The area shaded in red is the theoretical prediction for the scaling of ζ_0 with X for $\Gamma = 0.6-2.8$ eV/nm². The inset is a typical AFM image of the wrinkles formed between the two protrusions. The scale bar is 20 nm.

$$\zeta_{\pm}(x) = \left(\frac{27\kappa}{4E_{2D}}\right)^{1/6} \left[\frac{1}{\sin(\theta/2)} - 1\right]^{1/3} \left(\frac{X}{2} \mp x\right)^{2/3}. \quad (4)$$

In Fig. 3(a), we show the line profile along a wrinkle formed between two protrusions. The observed deflection is well fitted by the theoretical prediction $\zeta_{\pm}(x) \sim (X/2 \mp x)^{2/3}$ with a prefactor of 0.32 nm^{1/3}. Then, using $d = 7.4 \pm 2.2$ nm, $E_{2D} = 2.12 \times 10^3$ eV/nm² [10], $\kappa = 1$ eV [9], and $\Gamma = 0.6-2.8$ eV/nm² [17,28,32], we minimize the total energy E_{tot} numerically with respect to θ for a given X . Using Eq. (4), we find the maximum deflection $\zeta_0 \equiv \zeta(0)$ as a function of X as illustrated in Fig. 3(b). The maximum deflection ζ_0 monotonically increases with X , which is in good agreement with the observations. The

theoretical model for a deflection is based on the assumption that a wrinkle is formed between two sharp peaks. The finite sizes of the protrusions may be a cause of the decrease of the deflection below the theoretically expected range in Fig. 3(b). Furthermore, we attribute the most likely source of uncertainty to the observed dispersion in nanoparticle sizes.

Since a wrinkle is geometrically suppressed if $\zeta(0) > d$, the maximum length of the wrinkle is determined by a condition that $\zeta(0) = d$. From Eq. (4), we find the maximum length $X_c = 104\text{--}65$ nm along with $\theta = 35^\circ\text{--}14^\circ$ for the adhesion energy $\Gamma = 0.6\text{--}2.8$ eV/nm², respectively, in rough agreement with the observed maximum wrinkle length of approximately 200 nm [27]. Neglecting the contributions of $E_{b'}$ and $E_{\Gamma'}$, X_c slightly decreases to 96–62 nm. The discrepancy between the theoretical predictions and the observations is likely due to the fluctuations in the nanoparticle sizes d , which strongly influence the wrinkle length X_c (X_c increases in proportion to d). In Appendix B, we discuss the link between the detailed elastic model and the scaling analysis.

B. Random wrinkling model

Figure 4 shows the density of wrinkles ρ_w as a function of the nanoparticle density ρ_{np} and the number of wrinkles per protrusion ρ_w/ρ_{np} as a function of ρ_{np} (inset). We find that ρ_w is almost zero below $\rho_{np} \approx 25 \mu\text{m}^{-2}$ (arrow b) and then begins to increase rather linearly with ρ_{np} above $\rho_{np} \approx 50 \mu\text{m}^{-2}$ (arrow c). We now analyze the behavior of the wrinkle density ρ_w versus the nanoparticle density ρ_{np} within a simple model.

We first consider nanoparticles placed at random on the substrate [27]. Then wrinkles are placed with a probability

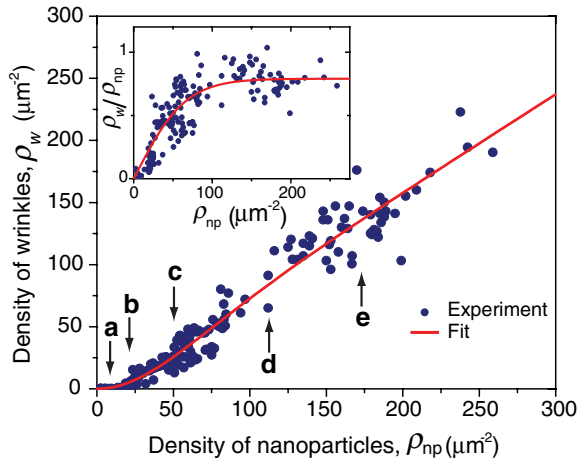


FIG. 4. The density of wrinkles ρ_w and the mean number of wrinkles per protrusion ρ_w/ρ_{np} (inset) as functions of nanoparticle density ρ_{np} . Each arrow corresponds to the AFM images shown in Figs. 1(a)–1(e). The solid red lines are fits described in text.

Ω_w between neighboring nanoparticles separated by less than a cutoff length X_c . The probability Ω_w is expected to encompass not only the true probability to make a wrinkle between nanoparticles, but also all the information about wrinkle-orientation correlations, selecting only a fraction of all possible wrinkles. Since nanoparticles with more than three connected wrinkles are scarcely observed [27], we set three as the maximum number of wrinkles. Employing the probability density for a nanoparticle to have the i th nearest nanoparticle ($i = 1, 2,$ and 3) at a distance r , $p_i(r) = 2(\pi\rho_{np})^{i+1}r^{2i+1}\exp(-\pi\rho_{np}r^2)/i!$ [33], we find the density of wrinkles:

$$\begin{aligned} \rho_w &= \frac{\rho_{np}\Omega_w}{2} \sum_{i=1}^3 \int_0^{X_c} dr p_i(r) \\ &= \frac{\rho_{np}\Omega_w}{2} \left[-\pi X_c^2 \rho_{np} \left(2 + \frac{1}{2} \pi X_c^2 \rho_{np} \right) e^{-\pi\rho_{np}X_c^2} \right. \\ &\quad \left. + 3(1 - e^{-\pi\rho_{np}X_c^2}) \right]. \end{aligned} \quad (5)$$

The factor of $1/2$ in ρ_w compensates for the double counting of each wrinkle (i.e., from the particles at each end). In the small nanoparticle density limit $\rho_{np} \ll X_c^{-2}$, the density of wrinkles is $\rho_w = (1/2)\Omega_w\pi X_c^2\rho_{np}^2$, while in the large density limit $\rho_{np} \gg X_c^{-2}$, each nanoparticle has at least three neighboring nanoparticles within distance X_c , leading to $\rho_w = (3/2)\Omega_w\rho_{np}$. The red solid lines in Fig. 4 are fits to Eq. (5) with $\Omega_w = 0.54$ and $X_c = 120$ nm. The cutoff length is consistent with the observations. Furthermore, the agreement with X_c predicted from the above elastic analysis is good. The model indicates a significant increase of the wrinkle density for the nanoparticle density larger than $(\pi X_c)^{-2}$, but also suggests that ρ_w does not exhibit any singularity; i.e., wrinkling is a crossover phenomenon rather than a sharp transition.

C. Percolation transition in the wrinkle network

With increasing ρ_{np} , the connectivity of the wrinkle network increases, and we find a percolation transition at a threshold density ρ_c (of order X_c^{-2}) at which the wrinkle network spans the system, as shown in the inset of Fig. 5(a). The expansion of the network via wrinkling is a purely two-dimensional (2D) phenomenon. Thus, we analyze this behavior using 2D percolation theory [34]: In Fig. 5(a), we plot the probability P that a given protrusion belongs to the percolating cluster spanning a region of size $L \times L$, where L ranges from 1 to 3 μm . Also plotted is the prediction from 2D percolation theory: $P \sim (\rho_{np} - \rho_c)^\beta$ for $\rho_{np} \geq \rho_c$ with $\rho_c = 87.5 \mu\text{m}^{-2}$ as determined below and the “magnetization” exponent $\beta = 5/36$ [34], which reproduces the observations well. In Fig. 5(b), we show the probability Π that a cluster connects opposite sides of a region of size $L \times L$ ($L = 0.5, 1, 2,$ and $3 \mu\text{m}$). For an infinite system, $\Pi = 1$ for $\rho_{np} \geq \rho_c$, while $\Pi = 0$ for

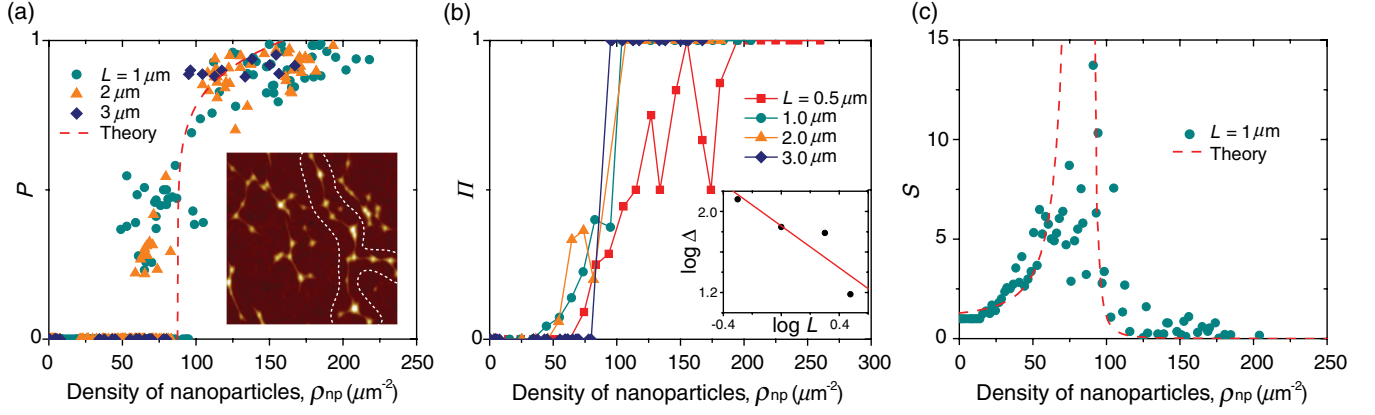


FIG. 5. (a) P as a function of nanoparticle density for $L = 1, 2,$ and $3 \mu\text{m}$. The inset is an AFM image ($1 \times 1 \mu\text{m}^2$) of graphene on the SiO₂ nanoparticles with a density of $57 \mu\text{m}^2$, showing the percolating cluster highlighted by the dashed curve. (b) Π as a function of the density of nanoparticles for $L = 0.5, 1, 2,$ and $3 \mu\text{m}$. Points for $L = 0.5, 1,$ and $2 \mu\text{m}$ represent averages in a bin of $10 \mu\text{m}^{-2}$. The inset is a plot of $\log \Delta$ as a function of $\log L$; the red line indicates a best-fit power exponent of -1.0 . (c) The mean finite cluster size S as a function of the density of nanoparticles (points represent averages in a bin of $2 \mu\text{m}^{-2}$). The red dashed line is the theoretical expectation (described in text).

$\rho_{\text{np}} < \rho_c$ [34]. Indeed, Π displays a sharp transition around $\rho_c = 87.5 \mu\text{m}^{-2}$ for $L = 3 \mu\text{m}$, indicating ρ_c is in that vicinity.

Next, we probe the width Δ of the transition region, which is expected to scale as $L^{-1/\nu}$, where $\nu = 4/3$ is the correlation-length exponent [34]. We define Δ as the difference in density for $\Pi = 0.9$ and $\Pi = 0.1$ in Fig. 5(b). The inset of Fig. 5(b) shows that the data are well fitted with $\nu = 1.0 \pm 0.3$, which is consistent with the theoretical expectation.

Finally, we plot in Fig. 5(c) the mean size S of the clusters (excluding the percolation cluster) as a function of ρ_{np} with the theoretical prediction $S \sim |\rho_{\text{np}} - \rho_c|^{-\gamma}$, where $\gamma = 43/18$ is the “susceptibility” exponent [34]. Some Monte Carlo simulations predict a much larger prefactor for $\rho_{\text{np}} \leq \rho_c$ (e.g., a critical amplitude ratio of 50 ± 26 for a continuum model [35]), which is in reasonable agreement with the observed ratio of approximately 30.

Thus, all measurements strongly support the existence of a 2D percolation transition at a critical nanoparticle density $\rho_c \approx 87.5 \mu\text{m}^{-2}$. Since the only length scale is X_c , we obtain a universal number (i.e., independent of model parameters such as Γ , E_{2D} , or d) characterizing the wrinkle percolation transition: $\rho_c X_c^2 \approx 0.9$. In contrast, the simple continuum percolation of penetrable discs of diameter X_c leads to $\rho_c X_c^2 \approx 2.9$ [35]. This difference is a consequence of the unique structure of the wrinkle network (e.g., no more than three wrinkles merging at a given nanoparticle [27]).

D. Delamination of graphene multilayers

Finally, we investigate morphological transitions which occur in multilayer graphene, using the same nanoparticle-templated substrates. The capability of

multiple layers of graphene to mechanically screen an asperity recalls the use of multiple mattresses in an attempt to hide the presence of a pea in the fairy tale “The Princess and the Pea.” Figures 6(a)–6(f) show typical AFM images of mono- and multi-layer graphene supported on nanoparticles of density $160 \pm 24 \mu\text{m}^{-2}$. The thicker graphene is partially suspended over the nanoparticles, as schematically shown in the insets of Figs. 6(d) and 6(f), with the delaminated area increasing with layer number n .

The phase image in Fig. 7 demonstrates that the suspended graphene is indeed supported by isolated nanoparticles; the mechanical response of the graphene to the AFM tip allows the detection of the hidden nanoparticle “peas” under the flat graphene “mattress.” The phase image records the varying phase angle of the (oscillating) AFM cantilever as it interacts with an inhomogeneous sample surface. The phase angle increases with increasing local sample stiffness [36]. Figure 7 shows that the phase image of 4-layer graphene discriminates between rigid supported regions (larger phase) and flexible suspended regions (smaller phase). The high, flat regions in the topograph show small, roughly circular regions of a large phase indicating the locations of the nanoparticles (arrows) that support the surrounding suspended graphene (small phase).

Figure 6(g) shows the areal fraction ϕ of graphene in contact with the substrate and the characteristic length l of the delaminated regions as functions of n . As n increases, a first transition occurs around $n = 10$, where l increases rapidly [Fig. 6(d), partial delamination]; second, ϕ decreases and becomes negligibly small above $n \sim 15$ [Fig. 6(f), complete delamination].

Surface-roughness-induced delamination of graphene has recently been studied theoretically [11,13,15] and experimentally [20,21,37]. Models assume the elastic energy

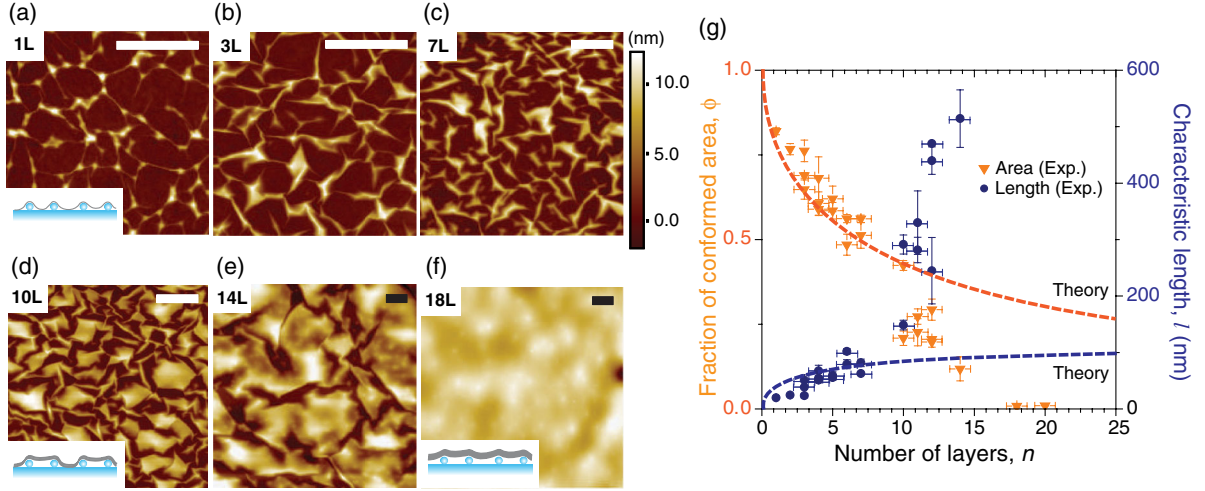


FIG. 6. Typical AFM images of (a) monolayer, (b) trilayer, (c) 7-layer, (d) 10-layer, (e) 14-layer, and (f) 18-layer graphene on SiO_2 with nanoparticle density $160 \pm 24 \mu\text{m}^{-2}$. The scale bar in each image is 400 nm. The insets in (a), (d), and (f) are corresponding schematics of graphene films on nanoparticles to the AFM images. (g) The fractional area ϕ where graphene conforms to the substrate and the characteristic length l of the delaminated domains, as functions of the number n of graphene layers. The dashed curves are the theoretical expectations for ϕ (orange) and l (blue) (described in text).

is dominated either by bending [11] or stretching [15]. Here we consider each regime, and assume that the adhesion energy between SiO_2 and n -layer graphene Γ_n is independent of n for $n > 1$ and has the value 1.9 eV/nm^2 [32]. In the bending-dominated model [11], unbinding is controlled by a single dimensionless parameter

$\alpha = (2\Gamma_n/\kappa_n)^{1/4}/[2\pi(\rho_{\text{np}}d)^{1/2}]$, where κ_n is the bending rigidity of n -layer graphene for $n > 1$. Without interlayer sliding [38], continuum plate elasticity [39] gives $\kappa_n = Et^3n^3/[12(1-\nu_g^2)]$, where $t = 0.335 \text{ nm}$ is the interlayer spacing, $E \approx 0.96 \text{ TPa}$ is the Young's modulus, and $\nu_g \approx 0.165$ is Poisson's ratio of monolayer graphene [10]. The threshold for partial unbinding is predicted at $0.8 \leq \alpha \leq 1.3$, or $3 \leq n \leq 6$, with complete unbinding at $0.55 \leq \alpha \leq 0.75$, corresponding to $7 \leq n \leq 10$ [11]. Thus, the bending-dominated model underestimates the critical value of n for unbinding, indicating that it overestimates the bending elastic energy. The one-dimensional character of the bending model limits its ability to make quantitative predictions. Furthermore, given the small radii of curvature in our experiment, the bending energy might well be reduced by partial interlayer sliding. Perfect sliding would give $\kappa_n = n\kappa$, leading to an unbinding threshold for n a hundredfold larger; hence, interlayer sliding is extremely effective in relieving bending stress.

We then develop a stretching-dominated model, using Schwerin's solution for a membrane pushed by a point force [40]. The solution gives the diameter of the detachment zone in n -layer graphene around a protrusion: $2R \approx d(4nE_{2D}/3\Gamma_n)^{1/4}$ (Refs. [15,41]; see also Appendix C), where nE_{2D} is the tensile rigidity of n -layer graphene. Then, we notice that the detached area around each protrusion is πR^2 and, furthermore, we assume that the detached areas produced by the wrinkles are negligible. Therefore, the typical length of the delaminated regions l is estimated to be $2R$. The adhered area fraction ϕ is equivalent to the probability of having no nanoparticle in a domain of an area of πR^2 , leading to $\phi = \exp(-\pi R^2 \rho_{\text{np}})$ (see Appendix D for details). As shown in Fig. 6(g), these

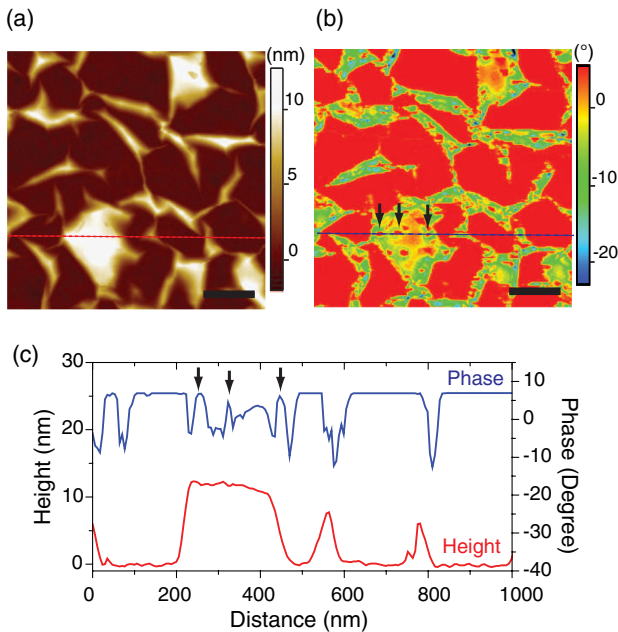


FIG. 7. Typical AFM (a) height and (b) phase images ($1 \times 1 \mu\text{m}^2$) of 4-layer graphene supported on the nanoparticles. The scale bar is 200 nm. (c) Line profiles of the height and phase along the dashed red and blue lines shown in (a) and (b), respectively. The arrows correspond to those in (b), showing the locations of nanoparticles beneath graphene.

predictions reproduce well the observed thickness dependence of ϕ and l below $n \approx 10$, indicating that the stretching-dominated model for isolated protrusions accurately describes the small- n limit where $\rho_{\text{np}} \ll l^{-2}$. However, l increases and ϕ decreases much more rapidly than these predictions for $n > 10$, indicating that collective effects have become important. In order to understand the collective delamination in the high-nanoparticle-density regime $\rho_{\text{np}} > l^{-2}$, we may need to solve full elastic membrane equations, i.e., the Föppl–von Kármán equations [39] allowing for multiple nanoparticles.

IV. PSEUDOMAGNETIC FIELDS IN WRINKLED GRAPHENE

Finally, while a complete treatment is beyond the scope of this paper, we briefly discuss the potential impact of wrinkles on the electronic properties of graphene. Strain in graphene produces a vector potential in the electronic Hamiltonian, with strain gradients resulting in effective magnetic fields [23]. Such pseudomagnetic fields generated by strain gradients have been proposed as the basis of engineering graphene’s electronic properties [24–26].

We first evaluate the pseudomagnetic field generated by strain gradients in the absence of wrinkling, corresponding to the case of small thickness or small nanoparticle density. In this case, the elastic behavior of graphene on nanoparticles is predominantly determined by stretching, resulting in significant strain. The radial strain ϵ_r and the circumferential strain ϵ_φ both scale as $(\Gamma d^2/E_{2D})^{1/3} r^{-2/3}$ at $0 < r < R$, although the radial strain is more than 5 times as large as the circumferential strain (see Appendix C and Ref. [42]). The gauge fields induced by the axisymmetric strain can be written as $(A_r, A_\varphi) \approx (\Phi_0 \beta/a)(\epsilon_r - \epsilon_\varphi) \times (\cos 3\varphi, \sin 3\varphi)$, where $\Phi_0 = 10^{-15}$ Wb is the flux quantum, $\beta \approx 2$ is the change in the hopping amplitude between the neighboring atomic sites due to the lattice deformation [43], $a = 0.142$ nm is the lattice constant, and φ is the azimuthal angle with $\varphi = 0$ in the zigzag direction [25]. Then, the strain-induced pseudomagnetic field is given by $B_{\text{eff}} = \partial_\varphi A_r/r - \partial_r A_\varphi - A_\varphi/r$. Thus, we find $B_{\text{eff}} \sim (\Phi_0 \beta/a)(\Gamma d^2/E_{2D})^{1/3} r^{-5/3} \sin 3\varphi$. The strain in graphene on an isolated nanoparticle induces threefold-symmetric pseudomagnetic field profiles with maximum fields along the armchair directions. The pseudomagnetic field pattern is similar to a recent experiment [44], in which suspended graphene was deformed by a sharp tip and pseudomagnetic fields were found to confine electrons to quantum dots with charging energies and level spacings both of order 10 meV. The divergence of the strain at $r = 0$ is cut off by the finite radius of the nanoparticles; thus, we may expect that the maximum pseudomagnetic field appears at a radius comparable to the nanoparticle radius. We therefore estimate that the maximum pseudomagnetic field B_{eff} is of order 300 T for $d = 7.4$ nm and $r = d/2$, which is significantly

greater than in Ref. [44], suggesting that the impact on electronic properties may be even more profound.

Next we evaluate strain and strain-induced pseudomagnetic fields in a wrinkle. Strain along a wrinkle is given by $\epsilon_x \approx (\partial_x \zeta)^2$. Then, using Eq. (4), we find the strain distribution $\epsilon_x \sim (\kappa/E_{2D})^{1/3}(X/2 \mp x)^{-2/3}$. The pseudomagnetic field is estimated to be $B_{\text{eff}} \approx \Phi_0 \beta \epsilon_x/(aW)$ [15,23], where W is the typical wrinkle width. In the strong adhesion limit $d(\Gamma/\kappa)^{1/2} \gg 1$, the wrinkle width W can be estimated to be $(\kappa/2\Gamma)^{1/2} \approx 1$ nm (see Appendix B). Thus, we find that, in the middle of a wrinkle, the pseudomagnetic field has a broad minimum on the order of 10 T for $X = 100$ nm. 10 T is a large magnetic field compared to the disorder strength $1/\mu \sim 1$ T in typical graphene samples (μ being the electron mobility) and corresponds to an energy difference between zeroth and first Landau levels of approximately 1300 K. Hence, we expect pseudomagnetic-field effects due to wrinkles in graphene to be significant.

The pseudomagnetic field near particles in the wrinkled case will generally be more complicated, depending on the number of wrinkles terminating on the particle and their direction with respect to each other and the lattice. However, qualitatively we expect that since wrinkling reduces the in-plane strain around the nanoparticles, the pseudomagnetic field is also reduced. Recent molecular dynamics simulation results [45] relevant to experiments by Tomori *et al.* [46] and our experiments of graphene on nanoparticles have indeed revealed that when nanoscale pillars supporting graphene are located far away from each other, graphene is detached only around the pillars and threefold-symmetric pseudomagnetic fields are induced around each pillar, while with decreasing distance between the pillars, graphene delaminates in regions between the pillars, resulting in complicated pseudomagnetic field profiles. Our observations of wrinkling and delamination combined with a theoretical analysis based on a continuum-elastic model can be used to place limits on strain distributions and thus, on pseudomagnetic field maxima realizable in monolayer graphene through adhesion to patterned surfaces.

V. CONCLUSIONS

In conclusion, combining experiments with monolayer and multilayer graphene, we have obtained a global picture of the structural evolution of graphene membranes on surfaces of varying roughness. With increasing nanoparticle density (or graphene thickness), this evolution proceeds in five stages: conformal adhesion, wrinkling, wrinkle percolation, partial delamination, and complete delamination. The results can be used to place upper limits on the magnitude of pseudomagnetic fields generated in graphene by adhesion to patterned surfaces. Finally, the wrinkling and delamination are not specific to graphene; they should be a general feature of soft membranes adhered

to rough surfaces, with implications for systems ranging from cell walls to fabrics.

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APPENDIX A: DETAILED GEOMETRIC MODEL FOR THE WRINKLE SHAPE

The stretching energy E_s , the bending energy E_b , and the adhesion energy E_Γ given by Eqs. (1)–(3) are reduced to

$$\begin{aligned} E_s &= \frac{E_{2D}}{2} \int dx w(x) \epsilon_x^2 \\ &= \frac{E_{2D}}{8} (\pi - \theta) \left[\frac{1}{\sin(\theta/2)} - 1 \right]^{-1} \int dx \zeta (\partial_x \zeta)^4, \quad (\text{A1}) \end{aligned}$$

$$\begin{aligned} E_b &= \frac{\kappa}{2} \int dx w(x) C_0(x)^2 \\ &= \frac{\kappa}{2} (\pi - \theta) \left[\frac{1}{\sin(\theta/2)} - 1 \right] \int dx \zeta^{-1}, \quad (\text{A2}) \end{aligned}$$

$$E_\Gamma = \Gamma \int dx W = 2\Gamma X d \tan(\theta/2). \quad (\text{A3})$$

The combination between the bending and the adhesion at the foot of the wrinkle forces an equilibrium curvature at the contact line $C_{\text{eq}} = (2\Gamma/\kappa)^{1/2}$ [47]. Then, assuming a simple geometry where a constant curvature region matches the constant slope region as shown in Fig. 2(b), we find the bending energy $E_{b'}$ and the adhesion energy $E_{\Gamma'}$ of the curved zone:

$$E_{b'} = 2 \frac{\kappa}{2} \int dx \int dy C_{\text{eq}}^2 = X \left(\frac{\Gamma \kappa}{2} \right)^{1/2} (\pi - \theta), \quad (\text{A4})$$

$$E_{\Gamma'} = 2\Gamma X C_{\text{eq}}^{-1} \tan\beta = X(2\Gamma\kappa)^{1/2} \tan\left(\frac{\pi - \theta}{4}\right), \quad (\text{A5})$$

where 2β is the angle of the curved region as shown in Fig. 2(b).

Minimization of the total energy $E_{\text{tot}} = E_s + E_b + E_\Gamma + E_{b'} + E_{\Gamma'}$ with respect to ζ leads to the following differential equation:

$$\zeta^2 \left[3(\partial_x \zeta)^4 + 12\zeta (\partial_x \zeta)^2 \partial_{xx} \zeta \right] + \frac{4\kappa}{E_{2D}} \left[\frac{1}{\sin(\theta/2)} - 1 \right]^2 = 0, \quad (\text{A6})$$

with the two boundary conditions $\zeta(\pm X/2) = 0$. We anticipate ζ to be symmetric with respect to x , so that $\partial_x \zeta$ should vanish at $x = 0$. However, Eq. (A6) indicates that if $\partial_x \zeta$ vanishes at $x = 0$, either ζ or $\partial_{zz} \zeta$ should diverge. Since the solution with diverging ζ is physically inconceivable, we conclude that $\partial_{zz} \zeta$ should diverge. This indicates a discontinuity of the slope at $x = 0$. Physically this singularity would be regularized at small scales either by bending along the x direction or by stretching along the y direction. These contributions are expected to be small. As a result, we obtain a simple solution on both sides of the center of the wrinkle as described by Eq. (4).

APPENDIX B: SCALING ANALYSIS FOR X_c

Here we show that X_c scales as $X_c \sim d(E_{2D}/\Gamma)^{1/4}$, which is analogous to scaling for the diameter of the detachment zone surrounding a local protuberance [15]. We design a scaling analysis, neglecting $E_{\Gamma'}$ and $E_{b'}$. The total energy is of the form

$$E_{\text{tot}} = \kappa^{5/6} E_{2D}^{1/6} X^{1/3} [f_1(\theta) + \Gamma d \kappa^{-5/6} E_{2D}^{-1/6} X^{2/3} f_2(\theta)], \quad (\text{B1})$$

where

$$f_1(\theta) = \frac{4}{3^{1/2}} (\pi - \theta) \left[\frac{1}{\sin(\theta/2)} - 1 \right]^{2/3} \quad (\text{B2})$$

and

$$f_2(\theta) = 2 \tan \frac{\theta}{2}. \quad (\text{B3})$$

The minimization of Eq. (B1) with respect to θ leads to

$$\partial_\theta f_1(\theta) + \Gamma d \kappa^{-5/6} E_{2D}^{-1/6} X^{2/3} \partial_\theta f_2(\theta) = 0 \quad (\text{B4})$$

and as a consequence

$$\theta = f_3(\Gamma d \kappa^{-5/6} E_{2D}^{-1/6} X^{2/3}). \quad (\text{B5})$$

The critical spacing X_c is given by a condition that $\zeta(0) = d$. Hence, using Eq. (4), we find

$$\begin{aligned} X_c &= d^{3/2} \frac{2^{3/2}}{3^{3/4}} \left(\frac{E_{2D}}{\kappa} \right)^{1/4} \left[\frac{1}{\sin[\theta(X_c)/2]} - 1 \right]^{-1/2} \\ &= d^{3/2} \left(\frac{E_{2D}}{\kappa} \right)^{1/4} f_4(\theta) \\ &= d^{3/2} \left(\frac{E_{2D}}{\kappa} \right)^{1/4} f_4(f_3(\Gamma d \kappa^{-5/6} E_{2D}^{-1/6} X_c^{2/3})), \quad (\text{B6}) \end{aligned}$$

where

$$f_4(\theta) = \left[\frac{1}{\sin(\theta/2)} - 1 \right]^{-1/2}. \quad (\text{B7})$$

One can check by substitution that

$$X_c = d^{3/2} \left(\frac{E_{2D}}{\kappa} \right)^{1/4} f_5(\Gamma d^2/\kappa), \quad (\text{B8})$$

with $f_6(u) = f_5(uf_6(u)^{2/3})$ and $f_5(u) = f_4(f_3(u))$. We now define the elastic thickness $h_{\text{el}} = (\kappa/E_{2\text{D}})^{1/2}$ and the equilibrium contact curvature $C_{\text{eq}} = (2\Gamma/\kappa)^{1/2}$. Letting $f_7(u) = f_6(u^2/2)$, we rewrite X_c as

$$X_c = \frac{d^{3/2}}{h_{\text{el}}^{1/2}} f_7(C_{\text{eq}}d), \quad (\text{B9})$$

which is the general scaling form of the solution.

We now consider two asymptotic limits; the strong adhesion limit $C_{\text{eq}}d \gg 1$ and the weak adhesion limit $C_{\text{eq}}d \ll 1$. In the strong adhesion limit, the opening angle of the wrinkle θ goes to zero. Then, one has $f_1(\theta) \sim \theta^{-2/3}$ and $f_2(\theta) \sim \theta$. Hence $f_3(u) \sim u^{-3/5}$. Since $f_4(\theta) \sim \theta^{1/2}$, one has $f_5(u) = f_4(f_3(u)) \sim [f_3(u)]^{1/2} \sim u^{-3/10}$, and finally $f_6(u) \sim u^{-1/4}$. Therefore one has

$$X_c \sim \frac{d^{3/2}}{h_{\text{el}}^{1/2}} (C_{\text{eq}}d)^{-1/2} \sim d(E_{2\text{D}}/\Gamma)^{1/4} \quad (\text{B10})$$

and

$$\theta \sim (C_{\text{eq}}d)^{-1}, \quad (\text{B11})$$

which also confirms that the small- θ limit corresponds to the large- $C_{\text{eq}}d$ limit (strong adhesion limit).

Alternatively, setting $\Theta = \pi - \theta$, we redo the above scaling analysis in the weak adhesion limit $C_{\text{eq}}d \ll 1$, with the argument of f_1, f_2 , and f_4 being Θ instead of θ . Then $f_1(\Theta) \sim \Theta^{7/3}$, and $f_2(\Theta) \sim \Theta^{-1}$, so that $f_3(u) \sim u^{3/10}$. Also $f_4(\Theta) \sim \Theta^{-1}$, leading to $f_5(u) \sim u^{-3/10}$ and $f_6(u) \sim u^{-1/4}$. Consequently, we obtain once again

$$X_c \sim \frac{d^{3/2}}{h_{\text{el}}^{1/2}} (C_{\text{eq}}d)^{-1/2} \sim d(E_{2\text{D}}/\Gamma)^{1/4} \quad (\text{B12})$$

and

$$\Theta \sim (C_{\text{eq}}d)^{1/2}. \quad (\text{B13})$$

This solution is consistent with the weak adhesion limit because $\Theta \ll 1$ implies $C_{\text{eq}}d \ll 1$.

APPENDIX C: STRETCHING OF GRAPHENE ON A NANOPARTICLE

The typical extent of the detachment zone of graphene caused by the presence of a nanoparticle is discussed here. In the simplest model, we use the power-law solution of Schwerin [40] in the regime dominated by stretching. In this regime, the bending rigidity only contributes as boundary-layer effects at the attachment lines [42]. Consequently, the Schwerin solution does not match tangentially to the substrate and the nanoparticle (the matching being forced at a smaller scale controlled by bending rigidity). Assuming that the nanoparticle diameter d is much smaller than the radius R of the detachment zone (see Fig. 8), we obtain the angle of rotation

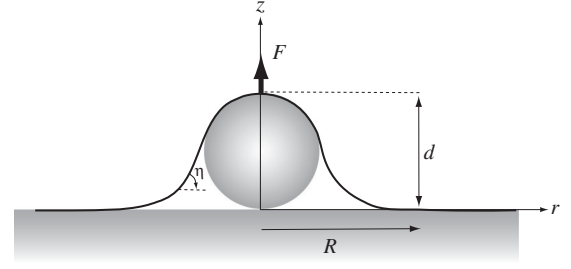


FIG. 8. Schematic of graphene supported on a single nanoparticle. The detachment length is R .

$\eta(r) = [8F/(9\pi E_{2\text{D}}r)]^{1/3}$ and the vertical distance from the substrate $Z = [3R^2F/(\pi E_{2\text{D}})]^{1/3}$ (see Fig. 8 and Ref. [42]), where F is the force on the apex. However, the above solution does not match the boundary conditions, and a better approximate numerical solution is $Z = g(\nu_g)(R^2F/E_{2\text{D}})^{1/3}$, where $g(\nu_g) = 1.0491 - 0.1462\nu_g - 0.15827\nu_g^2$ [42]. For graphene, $\nu_g = 0.165$ [10], and $g(\nu_g) \approx 1.029$ is very close to $(3/\pi)^{1/3} \approx 0.984$ so that we can safely use the direct Schwerin solution.

The elastic-stretching energy can be calculated from a gedanken experiment, where the height Z is increased with the constant R :

$$E(Z) = \int_0^Z dz F(z) = \frac{\pi E_{2\text{D}}}{3R^2} \int_0^Z dz z^3 = \frac{\pi E_{2\text{D}} Z^4}{12R^2}. \quad (\text{C1})$$

Assuming that the apex height is equal to the diameter d of the nanoparticle, one has $Z = d$, and the total energy reads

$$E(d) = \frac{\pi E_{2\text{D}} d^4}{12R^2} + \Gamma \pi R^2. \quad (\text{C2})$$

Minimizing the total energy with respect to R , one finds $2R/d = (4E_{2\text{D}}/3\Gamma)^{1/4}$ as suggested in Ref. [15].

Assuming that a preexisting strain is negligibly small, one can find radial and circumference components of the strain present in an isolated graphene protrusion at $0 < r < R$:

$$\begin{aligned} \epsilon_r(r) &= \frac{1}{E_{2\text{D}}} \left(\frac{G}{r} \cos \eta + H \sin \eta - \nu_g \frac{dG}{dr} \right) \\ &= \frac{3 - \nu_g}{4} \left(\frac{4\Gamma}{9E_{2\text{D}}} \right)^{1/3} \left(\frac{d}{r} \right)^{2/3}, \end{aligned} \quad (\text{C3})$$

$$\begin{aligned} \epsilon_\varphi(r) &= \frac{1}{E_{2\text{D}}} \left(\frac{dG}{dr} - \nu_g \frac{G}{r} \cos \eta - \nu_g H \sin \eta \right) \\ &= \frac{1 - 3\nu_g}{4} \left(\frac{4\Gamma}{9E_{2\text{D}}} \right)^{1/3} \left(\frac{d}{r} \right)^{2/3}, \end{aligned} \quad (\text{C4})$$

where $G = F/(2\pi\eta) = 9E_{2\text{D}}\eta^2 r/16$ is the stress variable in the radial direction, $H = F/(2\pi r) = 9E_{2\text{D}}\eta^3/16$ is the vertical sheet stress, and we assume $\eta \approx 0$ at $0 < r < R$ [42].

APPENDIX D: AREA PROBABILITY DISTRIBUTION

The probability $Q(A)$ that a nanoparticle has no nanoparticles in a domain of area A obeys $Q(A + dA) = Q(A) - dA\rho_{\text{np}}Q(A)$, leading to $dQ(A)/dA = -\rho_{\text{np}}Q(A)$. Using the normalization constraint

$$\lim_{A \rightarrow 0} Q(A) = 1, \quad (\text{D1})$$

we find $Q(A) = \exp(-\rho_{\text{np}}A)$.

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